



1763

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:
David J. Keller

Serial No.: 09/458,875

Filed: December 10, 1999

For: **POLYSILICON ETCH USEFUL DURING THE
MANUFACTURE OF A SEMICONDUCTOR
DEVICE**

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§ GAU: 1763
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§ Examiner: George Goudreau
§
§ Atty. Docket: 99-0738.00
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HC
5/1/02
AW

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Commissioner for Patents
Washington, D.C. 20231

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I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on or before the date below:

April 22, 2002

Date

Kevin D. Martin
Signature

RESPONSE TO THE RESTRICTION REQUIREMENT OF MARCH 22, 2002

In response to the Examiner's restriction requirement mailed March 22, 2002, applicants elect the species recited in claims 19, and 21-22 without traverse. Accordingly, applicant understands that all of claims 1-18, 19, 21-23, and 25-26 will be examined in the application, and that all of the pending claims may issue in the pending application if any of claims 1-18 are held to be allowable. As submitted by the Examiner, claims 19 and 21-22 define a first species, and claims 23 and 25-26 define a second species.

Respectfully Submitted,

Kevin D. Martin

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